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where



FIG. 11. The function $(W-W_I)T^{-1}$ versus T for Ge as a means of determining the extrapolated lattice thermal resistivity at high temperatures.

Thus

$$K = K_g + K_e + K_r, \tag{7}$$

where K_{q} is the phonon, K_{e} is the electronic, and K_{r} is the radiative or photon contribution to K.

Let us first consider the lattice thermal conductivity K_{a} . At high temperatures we have to consider the relaxation times τ_I and τ_U given in Eqs. (3) and (4), but we can neglect τ_B in Eq. (6). Equation (4) gives the relaxation time for 3-phonon umklapp processes. However, for 300° K $< T < 1681^{\circ}$ K, we are in the range of T comparable to or greater than the Debye temperature θ for both Si and Ge. In this range, it may be necessary to consider the relaxation times for four-phonon processes, as Pomeranchuck⁴⁵⁻⁴⁷ has pointed out. He gives a relaxation time for these higher order (H) processes as:

$$\tau_{H}^{-1} = B_{H} \omega^{2} T^{2}, \qquad (8)$$

with B_H a constant. K_{θ} can be evaluated for $T > \theta$ from Eqs. (1), (3), (4), and (8) if τ_c^{-1} is taken as

$$\tau_C^{-1} = \tau_U^{-1} + \tau_H^{-1} + \tau_I^{-1}.$$

In the region where $T > \theta$ the quantity x in Eq. (1) is small, and the integral simplifies to

$$K = \frac{k}{2\pi^2 v} \left(\frac{kT}{\hbar}\right)^3 \int_0^{\theta/T} \tau_C x^2 dx.$$
 (9)

45 I. Pomeranchuk, Phys. Rev. 60, 820 (1941).

⁴⁶ I. Pomeranchuk, J. Phys. USSR 4, 259 (1941).
 ⁴⁷ I. Pomeranchuk, J. Phys. USSR 7, 197 (1943).

Also the exponential factor in B_U disappears to make B_U temperature-independent. Thus

$$\tau_C^{-1} = (B_U T + B_H T^2) \omega^2 + A \omega^4. \tag{10}$$

For $T \geq \theta$ the isotope scattering is much less important than the phonon-phonon scattering. In this limit Eqs. (9) and (10) can be reduced by the method used by Ambegaokar,48 to

$$K_{g}^{-1} \equiv W_{g} = W_{U} + W_{H} + W_{I},$$

$$W_{U} = \pi v h B_{U} T / \theta k^{2},$$

$$W_{H} = \pi v h B_{H} T^{2} / \theta k^{2},$$

$$W_{I} = 4\pi^{2} V_{0} \theta \Gamma / h v^{2}.$$
(11)

This reduction requires $W_p \gg W_I$. This condition is fulfilled for Si and Ge at high temperatures. The only really unknown quantity in Eq. (11) is B_{II} . The quantities B_U and B_H can be evaluated experimentally from a plot of $(W_q - W_I)T^{-1}$ versus T. The quantity W_I is, except for a difference of a factor of 12 in the definition of Γ , the same as that given by Ambegaokar.⁴⁸ For Si one obtains $W_I = 0.033$ cm deg/W. For Ge the value is $W_I = 0.17$ cm deg/W using $V_0 = 2.26 \times 10^{-23}$ cm³, $\theta = 395^{\circ}$ K,⁴⁹ $\Gamma = 4.90 \times 10^{-5}$,⁵⁰ and $v = 3.94 \times 10^{5}$ cm/sec.

48 V. Ambegaokar, Phys. Rev. 114, 488 (1959).

- ⁴⁹ P. Flubacher, A. J. Leadbetter, and J. A. Morrison, Phil. Mag. 4, 273 (1959).
- ⁵⁰ D. Strominger, J. M. Hollander, and G. T. Seaborg, Rev. Mod. Phys. 30, 585 (1958).

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